

AMENDMENTS TO THE CLAIMS

1. – 8. (Cancelled)

9. (Currently Amended) A composition for photosensitive flexographic plates, comprising a
~~which comprises the~~ block copolymer composition for photosensitive flexographic plates
~~according to claim 1,~~ an ethylenically unsaturated compound and a photopolymerization initiator,
wherein the block copolymer composition comprises:

at least one kind of block copolymer (a) selected from block copolymers represented by the
following general formulae (a1) to (a3), and

a block copolymer (b) represented by the following general formula (b):

(A-B)₂X (a1)

(A-B)₃X (a2)

(A-B)₄X (a3)

A-B (b)

wherein A is a polymer block of an aromatic vinyl monomer, B is a polymer block of a conjugated
diene monomer, and X is a residue of a coupling agent having two or more functional groups of at least
one kind selected from an alkoxyl group, an ester group and an epoxy group in the general formulae a1,
a2, a3 and b,

and which satisfies the following relationships:

Wa = 50 to 100% by weight,

Wb = 0 to 50% by weight, and

$2.5 \leq (2 \times W2 + 3 \times W3 + 4 \times W4) / (W2 + W3 + W4) \leq 3.8$, wherein Wa, W2, W3, W4,
and Wb are the contents, in terms of % by weight, of (a),(a1),(a2),(a3),and(b), respectively.

10. (Cancelled)

11. (New) The composition for photosensitive flexographic plates according to claim 9, wherein the content of the aromatic vinyl monomer unit in the block copolymer composition for photosensitive flexographic plates is 5 to 25% by weight.

12. (New) The composition for photosensitive flexographic plates according to claim 9, wherein the weight-average molecular weight of the block polymer composition for photosensitive flexographic plates is 100,000 to 500,000.

13. (New) The composition for photosensitive flexographic plates according to claim 9, wherein the block copolymer composition for photosensitive flexographic plates comprises 0 to 20% by weight of the block copolymer (a1), 40 to 100% by weight of the block copolymer (a2), 0 to 50% by weight of the block copolymer (a3) and 0 to 50% by weight of the block copolymer (b).

14. (New) The composition for photosensitive flexographic plates according to claim 9, wherein the block copolymer composition for photosensitive flexographic plates comprises 55 to 95% by weight of the block copolymer (a) and 5 to 45% by weight of the block copolymer (b).

15. (New) The composition for photosensitive flexographic plates according to claim 14, wherein the block copolymer composition for photosensitive flexographic plates comprises 0 to 15% by weight of the block copolymer (a1), 40 to 95% by weight of the block copolymer (a2), 0 to 45% by weight of the block copolymer (a3) and 5 to 45% by weight of the block copolymer (b).

16. (New) The composition for photosensitive flexographic plates according to claim 9, wherein the block copolymer composition for photosensitive flexographic plates comprises 55 to 90% by weight of the block copolymer (a) and 10 to 45% by weight of the block copolymer (b).

17. (New) The composition for photosensitive flexographic plates according to claim 16, wherein the block copolymer composition for photosensitive flexographic plates comprises 0 to 10% by weight of the block copolymer (a1), 45 to 90% by weight of the block copolymer (a2), 0 to 45% by weight of the block copolymer (a3) and 10 to 45% by weight of the block copolymer (b).

18. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 9.

19. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 11.

20. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 12.

21. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 13.

22. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 14.

23. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 15.

24. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 16.

25. (New) A flexographic plate obtained by exposing, to light, the composition for photosensitive flexographic plates according to claim 17.